

710 U.S. 722-451 Pro  
09/11/2011

		Subclass	
	Class		ISSUE CLASSIFICATION

PATENT NUMBER

**U.S. UTILITY Patent Application**

D.I.P.E.  
SCANNED A/S (2) Q.A. A/A

PATENT DATE

APPLICATION NO. 09/722454	CONT/PRIOR D F	CLASS 445	SUBCLASS 24	ART UNIT 2879	EXAMINER Santias
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**Method for manufacturing electron beam device, method for manufacturing image forming apparatus, electron beam device and image forming apparatus manufactured those manufacturing methods, method and apparatus for manufacturing electron source, and**

## **ISSUING CLASSIFICATION**

TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.				<b>NOTICE OF ALLOWANCE MAILED</b>	
<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____				<b>ISSUE FEE</b>	
	(Assistant Examiner)	(Date)		Amount Due	Date Paid
	(Primary Examiner)	(Date)		<b>ISSUE BATCH NUMBER</b>	
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